Bandgap and band edge positions in compositionally graded ZnCdO

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Introducing Cd into ZnO allows for bandgap engineering, potentially with particularly interesting properties to observe in compositionally graded samples. In this work, compositionally graded Zn₁₋ₓCdₓO samples with 0 ≤ x < 0.16 were made using metal organic vapour phase epitaxy. The chemical composition was studied using scanning transmission electron microscopy, while the band structure of the samples was investigated using a combination of cathodoluminescence spectroscopy and X-ray photoelectron spectroscopy (XPS). It is found that the reduction of the bandgap in our samples is caused by changes in the conduction band. The position of the Fermi level relative to the vacuum level, i.e., the workfunction, was also found to change upon addition of Cd, giving an apparent shift in the valence band when evaluated from the XPS valence spectra.

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I. INTRODUCTION

Group-II oxides represent direct wide-bandgap semiconductors that share many attractive features with group-III nitrides, making them promising for electronic applications. The unique combination of high exciton binding energy and the broad bandgap tunability range from 4.8 eV to 1.8 eV in wurtzite MgO-ZnO-CdO compounds can benefit a number of modern device applications, including recently demonstrated solar-blind photodetectors, thin-film transistors (TFTs) for smart displays, tandem solar cells, as well as in yet to be established approaches in realizing light emitting diodes (LEDs), resistive switching (RS) devices, etc. 1–7 These developments, however, are hampered by several unresolved issues, notably by unreliable p-type doping, phase separation in ternary alloys, etc. Indeed, ZnO exhibits native n-type conductivity, and numerous attempts to convert it to p-type by controlling acceptor-type intrinsic defects (zinc vacancy VZn and oxygen interstitials Oi) and by doping with relevant acceptor impurities (N, Na, P, Ag, etc.) have had very limited success so far.3

A fundamentally new way to create conductivity in noncentrosymmetric crystal structures, called polarization-induced doping (PID), was proposed by Jena et al.9 and later demonstrated in III-nitrides by grading the composition of AlGaN along its c-axis, the direction along which the polarization dipoles lie in wurtzite.10 In uniaxial crystals, spontaneous polarization arises due to the ionic character of the bonds between atoms and their asymmetric positions within the structure. For noncentrosymmetric crystals with a composition varying along the direction of the dipoles, a fixed (bound) polarization charge builds up because the neighbouring dipoles in the graded alloy are not of the same magnitude anymore and thus no longer cancel each other. To maintain the overall charge neutrality, the bound polarization charge accumulated in the crystal must be compensated by mobile (free) charge carriers, which can be provided from elsewhere, e.g., the surface states.11 The outcome of such charge rearrangements is n-type (or p-type) conductivity with bound polarization charge acting as a local donor (or an acceptor) with zero activation energy, as well as higher carrier mobilities due to removal of ionized impurity scattering. Compositionally graded ZnCdO and ZnMgO have raised interest as possible candidates for PID. By taking advantage of the large polarization charges typical for group II oxides and controlling the composition gradient during synthesis, the resultant electric fields can be arranged in a way to create spatially separated electrons or holes without introducing dopants, potentially resolving the doping asymmetry inherent to this family of wide-bandgap semiconductors. Moreover, compositionally graded films are used as buffer layers to synthesize, e.g., ZnMgO exhibiting an ultimately high Mg content.1 Altogether, this makes investigations of such compositionally graded samples of high interest.

Introducing Cd into ZnO reduces the bandgap (Eg), but no general framework exists for predicting the position of the band edges of Zn₁₋ₓCdₓO relative to the Fermi level (EF). The Eg reduction can be accommodated by changes either in the valence band, the conduction band, or both. Furthermore, the influence of intrinsic defects on the band structure may change as the bandgap changes, affecting the position of the Fermi level relative to the band edges, e.g., making the semiconductor material more or less p- or n-type. When materials are combined to form heterojunctions, which is central to advances in device development, the Fermi levels of the different materials will line up. The core, valence, and conduction bands may thus have to bend to make up for band structure mismatches between the two materials. It is largely the shape of the band bending across the interface, e.g., formation of barriers, which controls the device functions. This
shape relies on the difference in workfunctions and the alignment of the band edges. To some extent, models for predicting the shape of band bending across interfaces exist for certain material classes, but a general understanding is still lacking.\textsuperscript{12–14} Particularly for new alloyed materials such as \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \), characterization of the band structure is important for potential applications.

In a density functional theory (DFT) study of the electrical and optical properties of \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) with \( x \leq 0.25 \), Zhang \textit{et al.}\textsuperscript{15} found the bandgap decrease to be caused by changes in the conduction band. An increase in \( s \) states was observed upon introduction of Cd, shifting the Zn 4s states in the lowest conduction band closer to the O 2p states in the highest valence band. To date, only a few X-ray photoelectron spectroscopy (XPS) based studies of band edge positions in \( \text{ZnCdO} \) have been reported, with diverging conclusions. According to Chen \textit{et al.},\textsuperscript{16} who studied molecular beam epitaxy grown samples with composition \( \text{Zn}_{0.95}\text{Cd}_{0.05}\text{O} \), both the valence band maximum (E\textsubscript{V}) and the conduction band minimum (E\textsubscript{C}) move relative to the Fermi level, by +0.17 eV and −0.30 eV, respectively. In a study of calcinated \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) samples with \( x = 0, 0.039, 0.075, \) and 1, Lai \textit{et al.} also found that both band edges shift but with the same magnitude.\textsuperscript{17} In the work of Detert \textit{et al.}, however, it was concluded that the decrease in the bandgap was due to shifts in E\textsubscript{V} only, for pulsed filtered cathodic arc deposited samples with \( x = 0.11, 0.29, 0.56, 0.74, \) and 1.\textsuperscript{18}

In the present work, we study the composition and bandgap energy (E\textsubscript{g}) of four compositionally graded \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) samples with \( 0 \leq x < 0.16 \) using transmission electron microscopy (STEM) and cathodoluminescence spectroscopy (CL), respectively. XPS is used to find the position of E\textsubscript{V} relative to the Fermi level, which is combined with E\textsubscript{g} from CL to determine the position of E\textsubscript{C}.

### II. METHODS

Thin film samples of \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) with varying Cd concentrations were prepared by metal organic vapour phase epitaxy (MOVPE) along the \( c \) axis of \( \alpha\text{-Al}_2\text{O}_3 \) substrates buffered with a ZnO film. The substrates were cleaned with several solutions, rinsed with deionized water, and then dried with N\textsubscript{2} gas before loading into the chamber. Diethyl zinc (DEZn), dimethyl cadmium (DMCd), and tertiary butanol (t-BuOH) were used as the zinc source, cadmium source, and oxidizing agent, respectively. For DEZn and t-BuOH, the flows were set at 100 and 150 sccm, respectively. The temperatures of both DEZn and DMCd bubblers were maintained at 10°C, while that of t-BuOH was kept at 30°C. The Cd content in the films was varied by changing the DMCd flow rate while maintaining the growth temperature at 370°C, which means increasingly metal-rich (oxygen-poor) conditions for increasing Cd supply. The samples were labelled according to their maximum Cd content as measured by energy-dispersive X-ray spectroscopy (EDS) (see details below).

XPS was performed using a Thermo Theta Probe instrument with monochromatic Al K\textsubscript{α} radiation (\( h\nu = 1486.6 \text{ eV} \)) operated at 15 kV and 15 mA. High resolution spectra were collected at a pass energy of 20 eV and a step size of 0.1 eV for core/Auger peaks and 0.05 eV for the VBM region. See Fig. 1 for a typical XPS survey spectrum and the definition of relevant parameters. An area of about 2 × 2 mm\textsuperscript{2} was gently cleaned with an Ar\textsuperscript{+} ion beam of 0.5 kV delivering a current of 100 µA for 5 min. In order to ensure good electrical contact between the sample and the XPS instrument, Al contacts with...
after Shirley background subtraction, using the CasaXPS energy electron charge compensation. XPS spectra were fitted the measurements could be performed without the use of low contact between the sample and the XPS instrument, and Thus, the Al contacts were concluded to improve the electri-

can be seen, for electron beam energies up to 0.5 kV, the penetration depth is in the range of 1–10 nm, which matches the sampling depth of the XPS technique. The CL spectra were fitted using the CasaXPS software. The bandgap information was extracted from the NBE peaks, which were fitted with a series of phonon replicas with 72 meV spacing. The CL spectrum from the pure ZnO sample was used as a starting point for determining the shape of the NBE peaks in the Zn1−xCd0xO samples. Figure 2(b) shows an example of a CL spectrum with a fitted NBE peak.

For STEM studies, samples were prepared by mechani-

cal cutting, grinding/polishing, and ion beam thinning. The compositions were studied by EDS with a probe-corrected FEI Titan 60–300 instrument, which was operated in the STEM mode at 300 kV. In this mode, a spatial resolution of 0.8 Å can be achieved for probe-corrected STEM imaging. The EDS maps and spectra were collected using the FEI Super-X EDS setup with four EDS detectors, thereby increasing the signal counts. Before STEM-EDS mapping, the sapphire substrate was tilted in the [2110] zone axis, so as to make the electron beam parallel to the substrate/film interface and perpendicular to the film growth direction, the c axis of the sapphire substrate. The maps and spectra were analyzed using the Bruker Esprit 1.9 software. The absolute error in the quantification was determined to be below 4.70 at. %. For an in-depth STEM study of the samples, see the recent publication by Zhan et al.

The resistivity and charge carrier density were measured at room temperature with a LakeShore 7704A Hall Measurement System using a Van der Pauw configuration. Sample thicknesses were estimated from STEM images.

### III. RESULTS AND DISCUSSION

Figure 3 shows the results from the STEM-EDS investigation of the samples. In order to accurately quantify the vertical grading, the compositions were averaged over areas of 109 nm × 3 nm (Cd05), 53 nm × 4 nm (Cd09), 408 nm × 3 nm (Cd13), and 440 nm × 3 nm (Cd16) to produce the line profiles in Fig. 3(a). As an illustration, Figs. 3(b) and 3(c) show the EDS mapping of Cd and Zn, respectively, from sample Cd13. The Cd containing film is clearly distinguishable from the ZnO buffer layer. Both layers are typically about 100–120 nm thick. All samples reveal statistically significant variations in the Cd content. For the samples Cd05, Cd09, and Cd16, the Cd content is the highest closest to the pure ZnO interface and decreases in a nearly linear manner towards the sample surface. For sample Cd13, the Cd content is the highest in the middle of the Zn1−x Cd0xO film, after which it drops off again towards the sample surface. The data are listed in Table I. Quantitative XPS analysis was used to determine the surface composition of the samples after gentle Ar+ sputter removal of the carbon contamination layer. At the surface, Cd05, Cd09, Cd13, and Cd16 were found to have x = 0.01, 0.03, 0.05, and 0.08, respectively. This is generally somewhat lower than the compositions measured by STEM-EDS in Fig. 3. This can be due to the fact that the STEM-EDS investigation does not provide the true composition at the outermost surface, e.g., because of surface roughness. Some

![FIG. 2. (a) Calculated electron energy loss in pure ZnO as a function of the sample depth for different electron beam energies. (b) CL spectrum from pure ZnO, illustrating the fitting of the NBE peak with phonon replicas.](image-url)
preferential sputtering may also occur although the sputter yields of Zn and Cd are not severely different.\textsuperscript{24}

Figure 4 shows CL spectra from the samples studied by STEM-EDS. A clear shift in the NBE peak position is seen as a function of the electron beam energy. In general, the bandgap decreases with increasing electron beam energy, i.e., deeper penetration depth, consistent with the variation in the Cd content found from STEM-EDS. For each sample, the spectrum acquired at the lowest beam energy was peak fitted in order to extract bandgap values from the sample depth corresponding to the XPS measurement. The fitting strategy for such samples is not unambiguous: As shown in Fig. 2(b), the NBE peak contains several phonon replicas, resulting in an asymmetric overall peak shape with the true NBE position shifted to slightly higher energies than the apparent peak maximum. The width, separation, and relative intensity of the replicas depend on the material and are not known for the Zn\textsubscript{1−x}Cd\textsubscript{x}O system. Furthermore, the compositional inhomogeneity of the samples means that the CL spectrum will consist of several overlapping NBE peaks from different sample regions exhibiting different bandgaps. For the present purpose, we chose a simplified fitting procedure focusing on comparability between the different samples: The spectra were fitted with one main NBE peak, consisting of replica peaks with separation and relative intensity taken from pure ZnO. The full-width-at-half-maximum (FWHM), however, was allowed to increase compared to pure ZnO in order to represent the spread in bandgap values within the measurement volume. A limited number of generic peaks were added to the lower energy region to represent unknown/unresolved defect peaks. This was done in order to avoid unphysical behavior of the NBE peaks, as detailed analysis of the defects in the Zn\textsubscript{1−x}Cd\textsubscript{x}O system was beyond the scope of this work. For Cd\textsubscript{05} and Cd\textsubscript{09}, the NBE peak of pure ZnO was added to the higher energy side. More elaborate peak fitting schemes were explored but not found to offer increased accuracy due to the large number of unknown variables. The fitted CL spectra are shown in Fig. 5, and the extracted bandgap values are listed in Table I.

Detailed XPS measurements of the valence region were conducted in order to find the position of E\textsubscript{V} as a function of the Cd content. A nearly linear shift in E\textsubscript{V} as a function of x is seen in Fig. 6(a). An important thing to remember at this point, however, is that XPS measures energies relative to E\textsubscript{F}. Thus, if the E\textsubscript{F} position shifts within the bandgap, i.e., if the workfunction of the material changes, the entire XPS spectrum will shift accordingly. The work function can be affected by changes in two independent quantities: (1) The distance between E\textsubscript{F} and the band edges and (2) the distance between the vacuum level (E\textsubscript{vacuum}) and the band edges, i.e., the ionization potential (I\textsubscript{P}) or the electron affinity (\textit{\textgamma}).\textsuperscript{25} Changes in the E\textsubscript{F} position can be seen as a result of doping or surface band bending. In the case of Zn\textsubscript{1−x}Cd\textsubscript{x}O, there is also a change in the magnitude of the bandgap, which may affect the position of the Fermi level in unknown ways. These aspects complicate the comparison of absolute E\textsubscript{V} positions between the samples. After analyzing the core spectra, however, it was found that the distances between E\textsubscript{V}.

<table>
<thead>
<tr>
<th>Sample name</th>
<th>Maximum Cd content\textsuperscript{a} x</th>
<th>Surface composition\textsuperscript{b} x</th>
<th>E\textsubscript{V} position relative to E\textsubscript{F} (eV)</th>
<th>Auger parameter Zn 2p-LMM (eV)</th>
<th>Surface bandgap\textsuperscript{c} E\textsubscript{g} (eV)</th>
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<tr>
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<td>0.00</td>
<td>3.24(5)</td>
<td>2010.08(14)</td>
<td>3.31</td>
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<td>3.24(5)</td>
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<td>Cd\textsubscript{09}</td>
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<td>0.03</td>
<td>3.14(5)</td>
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<td>3.03</td>
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<tr>
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<td>0.05</td>
<td>3.05(5)</td>
<td>2010.15(14)</td>
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</tr>
<tr>
<td>Cd\textsubscript{16}</td>
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<td>0.08</td>
<td>2.88(5)</td>
<td>2010.13(14)</td>
<td>2.80</td>
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</tbody>
</table>

\textsuperscript{a} Measured by STEM-EDS.
\textsuperscript{b} Measured by XPS.
\textsuperscript{c} Measured by CL.
and the Zn 2p, Cd 3d, and O 1s core level peaks were constant in all the samples, within the accuracy of the measurements [see Fig. 6(b)]. The Zn 2p-LMM Auger parameter\(^{26}\) (AP) was also found to be constant (see Table I). It is highly unlikely that the introduction of Cd would cause both the valence levels and the core levels to shift by exactly the same amount. Sample charging, which is another possible source of uniform peak shifts, was already tested and ruled out. Thus, if we interpret the constant \(E_V\)-to-core level distances and APs as a sign that Cd does not cause changes in

![Image](image1.png)

**FIG. 4.** CL spectra from samples Cd05 (a), Cd09 (b), Cd13 (c), and Cd16 (d). The region around the NBE peak maximum is enhanced, while the full spectra are included as insets. In general, a decrease in the bandgap is observed with increasing electron beam energy, i.e., the increasing sample depth, in agreement with the gradient in the Cd content.

![Image](image2.png)

**FIG. 5.** CL spectra (black solid) from the outermost surface (the lowest electron beam energy) of samples Cd05 (a), Cd09 (b), Cd13 (c), and Cd16 (d). The NBE peaks of \(\text{Zn}_1-\text{Cd}_x\text{O}\) (red dot) and pure \(\text{ZnO}\) (blue short dash) are fitted with a series of phonon replicas. The position of the first peak gives the bandgaps (\(E_g\)) listed in Table I. A limited number of generic peaks (grey dash) were added in order to represent unknown/unsolved defects on the lower energy side.
the valence and core levels, i.e., $I_p$ remains constant for the increasing Cd content, the relative bandstructure of the $\text{Zn}_{1-x}\text{Cd}_x\text{O}$ samples can be established using the core levels for the alignment. In Fig. 7, $E_V$ and core levels are aligned, while the distance between $E_F$ and $E_{\text{vacuum}}$ is seen to increase with the increasing Cd content. The $E_C$ position is found using the bandgap values as measured by low electron energy CL. Two things are worth noting from Fig. 7: (i) For the present samples, the change in $E_g$ due to Cd appears to be accommodated primarily by changes in the conduction band. (ii) For all samples except Cd05, $E_F$ appears to lie above $E_C$. Additional work is needed to clarify whether the latter is a bulk material property or just a surface bandbending effect observed by XPS.

In Fig. 8(a), the results of Hall measurements show an increased carrier concentration as a function of the increasing Cd content. For pure ZnO, the growth conditions are slightly oxygen-rich, but with an increased DMCd-flow, the growth conditions shift towards oxygen-poor/metal rich since the flow rate of t-BuOH is kept constant for all samples, explaining this general trend of the increasing carrier concentration. However, for the highest Cd content (Cd16 sample), the carrier concentration is again reduced as compared to the Cd13 sample. Interestingly, the mobility is at the same time increased (not shown), which is consistent with a higher incorporation of Cd on the Zn-site combined with a lower Cd-interstitial donor concentration in the film. At low DMCd flow rates, the incorporation efficiency of Cd into ZnO is low and Zn/Cd-rich conditions introduce $\text{Zn}_i$ (or Cd$_i$), which acts as a donor. However, at a high DMCd flow rate, the Cd incorporation efficiency increases, in turn

The valence and core levels are included to illustrate the method for $E_C$ determination. The inset shows the distance between $E_V$ and $E_F$ with standard deviations, as measured from the XPS valence spectra. (b) The energy difference between $E_V$ and relevant core level peaks with standard deviations, as measured by XPS.

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influencing the formation of interstitial defects. A similar trend was observed by Kumar et al. in samples synthesized by reactive de magnetron sputtering.\textsuperscript{28}

In the work of Makino and Segawa Ga-doped, ZnO was found to have \( E_F > E_C \) at 300 K for carrier concentrations exceeding \( 10^{19} - 10^{20} \text{ cm}^{-3} \).\textsuperscript{29} This indicates that the carrier concentrations measured for the present \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) samples are in the correct order of magnitude to exhibit degenerate behavior. However, the extraction of values for the carrier concentration from Hall measurements does not take into account the compositional grading. Figure 8(b) shows temperature dependent Hall measurements for the \( \text{Cd}_{16} \) sample. These measurements suggest the semiconductor behavior, as the resistivity decreases with increasing temperature. Alternatively, the \( E_F > E_C \) behavior may also be an effect of surface bandbending. Previously, a strong downward surface bandbending effect has been reported for pure ZnO.\textsuperscript{30}

Furthermore, extreme downward bandbending and \( E_F > E_C \) were also observed for rocksalt-phase \( n \)-type \( \text{CdO} \), caused by an accumulation of electrons forming quantized electron subband states near the surface.\textsuperscript{31} Thus, a similar effect could be present for \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) as well.

The bandstructure data discussed so far were extracted from the near-surface area of different samples. In the following paragraph, we combine the surface data from these samples to predict the band structure evolution along the growth direction of a compositionally graded \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) film. The position of \( E_V \) relative to \( E_F \) was obtained from the XPS data, while \( E_V \) could be combined with \( E_F \) found by CL, to determine the position of \( E_C \). The obtained \( E_V \) and \( E_C \) values were plotted as a function of the Cd content and fitted with linear functions. These graphs were in turn incorporated into a schematic illustration of the graded \( \text{ZnCdO} \) (\( n \)-type) side of a possible PID-junction, as presented in Fig. 9. It is important to note that the change in the position of \( E_V \) relative to \( E_F \) in this representation of the data is not an indication of changes in the valence band. In Fig. 9, the Fermi levels are aligned, which is what happens upon electrical contact. This gives the impression that the valence band changes but is in reality an effect of bandbending, where the compositionally graded film behaves similar to a heterostructure made of very thin layers.

**IV. CONCLUSIONS**

The bandgap and band edge positions of compositionally graded \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) samples made by MOVPE were investigated using a combination of XPS and CL. Common pitfalls related to XPS energy referencing were resolved. First, it was shown how sample charging during XPS measurements can be minimized by depositing proper metal contacts onto the \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) samples. Second, it was emphasized how changes in the Fermi level position relative to vacuum, i.e., the work-function, complicate the comparison of XPS data from different samples. Taking the latter into account, it was found that introducing Cd into ZnO does not significantly alter the band structure below the Fermi level. Hence, the reduction of the bandgap upon alloying with Cd must be accommodated primarily by changes in the conduction band. Bandgap values were obtained from low energy CL and combined with the XPS data to sketch the band structure of graded \( \text{Zn}_{1-x}\text{Cd}_x\text{O} \) heterostructures.

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